

# Optimizing precision of rotating compensator ellipsometry

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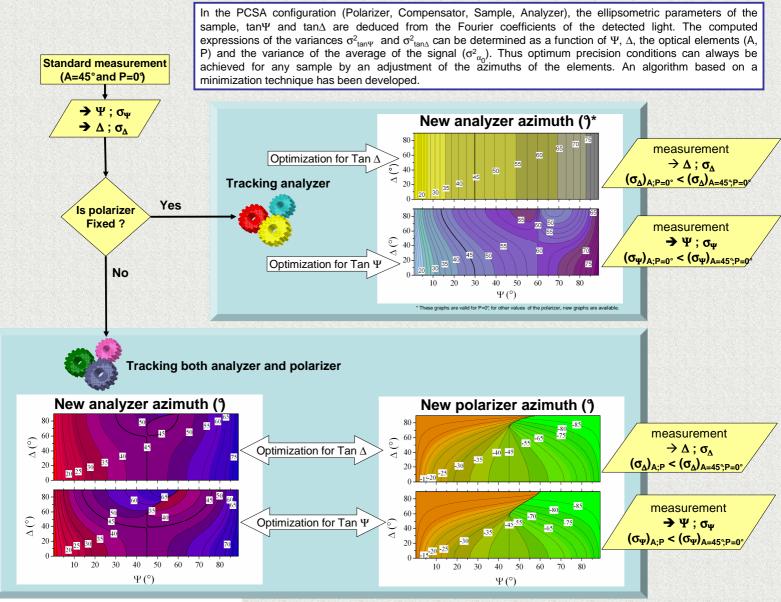
# Optimizing precision of rotating compensator ellipsometry

### L. Broch and L. Johann

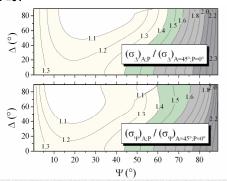
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Many authors proposed algorithms and methods for the calibration of the elements and for the reduction of the errors in measurements in order to increase the performance of ellipsometers [1-3]. In particular, an optimized tracking method which reduces random errors has been applied on rotating polarizer ellipsometry [4]. The aim of this work is to propose a method especially adapted to the RCE ellipsometers when measurements with a high degree of accuracy are required.



 $\sigma_{\!\scriptscriptstyle \Psi}$  and  $\sigma_{\!\scriptscriptstyle \Delta}$  with tracking both analyzer and polarizer compared to  $\sigma_{\!\Psi}$  and  $\sigma_{\!\Delta}$  obtained with A=45° and P=0°



positions of the optical determined by this method increase the signalto-noise ratio. Consequently, the random errors decrease and the precision of the ellipsometric angles of the sample increase. measurements validate and confirm improvement of this method. The standard deviation of the  $\Psi$  and  $\Delta$  angles measured by the tracking both analyzer and polarizer is always lower than the standard deviation obtained by the tracking analyzer alone. We note that better results are obtained with samples where  $\Psi$  is  $\leq 10^{\circ}$  or  $\geq 50^{\circ}$ .

#### Measurements for a 125nm-SiO<sub>2</sub>/SI sample (\lambda=633nm and 70° of incidence)

	Standard	Tracking	analyzer	Tracking both analyzer and polarizer	
	A=45°,P=0°	A=47.38°,P=0°	A=62.14°,P=0°	A=47.46°,P=-84.85°	A=35.0°,P=-87.83°
Ψ (°)	63.982	63.967			63.972
$\sigma_{\Psi}$	0.012	0.011			0.006
Δ (°)	84.430		84.448	84.435	
$\sigma_{\Delta}$	0.033		0.030	0.022	

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